

Title (en)
METHOD AND SYSTEMS FOR ELECTROMAGNETIC PROTECTION WITH PERSISTENT SELF MONITORING AND CYBERSECURE LOCAL AND REMOTE STATUS REPORT

Title (de)
VERFAHREN UND SYSTEME FÜR ELEKTROMAGNETISCHEN SCHUTZ MIT PERSISTENTER SELBSTÜBERWACHUNG UND CYBERSICHERER LOKALER UND ENTFERNTER STATUSBERICHT

Title (fr)
PROCÉDÉ ET SYSTÈMES DE PROTECTION ÉLECTROMAGNÉTIQUE AVEC SURVEILLANCE AUTOMATIQUE PERMANENTE ET RAPPORT D'ÉTAT LOCAL ET DISTANT CYBERSÉCURISÉ

Publication
EP 4348788 A1 20240410 (EN)

Application
EP 22936010 A 20220909

Priority

- US 202217706041 A 20220328
- US 2022043087 W 20220909
- US 201862615159 P 20180109

Abstract (en)
[origin: US2019214814A1] A system and method for suppressing EMP-induced electrical system voltage surges due to detonation of a nuclear weapon, the EMP comprising E1, E2, and E3 component pulses. A plurality of shunting assemblies, each including MOVs, gas discharge tubes, other mechanical, electrical and ionization discharge devices and combinations thereof, detect and react to the overvoltage according to timing parameters associated with each of the E1, E2, and E3 components and shunt the overvoltage to decrease to under a predetermined allowable level.

IPC 8 full level
H02H 9/04 (2006.01)

CPC (source: EP US)
G01R 31/12 (2013.01 - US); **G01R 31/327** (2013.01 - US); **H02H 5/00** (2013.01 - US); **H02H 5/005** (2013.01 - EP US); **H02H 9/005** (2013.01 - EP); **H02H 9/04** (2013.01 - US); **H02H 9/041** (2013.01 - EP); **H02H 9/045** (2013.01 - US); **H02H 3/08** (2013.01 - US); **H02H 3/105** (2013.01 - US); **H02H 3/22** (2013.01 - US); **H02H 9/041** (2013.01 - US); **H02H 9/046** (2013.01 - US)

Designated contracting state (EPC)
AL AT BE BG CH CY CZ DE DK EE ES FI FR GB GR HR HU IE IS IT LI LT LU LV MC MK MT NL NO PL PT RO RS SE SI SK SM TR

Designated extension state (EPC)
BA ME

Designated validation state (EPC)
KH MA MD TN

DOCDB simple family (publication)
US 10530151 B2 20200107; US 2019214814 A1 20190711; AU 2019206390 A1 20200730; AU 2019206390 B2 20210225; AU 2020361439 B2 20220414; AU 2022450393 A1 20240201; AU 2022450393 B2 20240912; BR 112020013897 A2 20201201; BR 112022006478 A2 20220906; CA 3088002 A1 20190718; CA 3088002 C 20221018; CA 3153874 A1 20210415; CA 3153874 C 20230207; CA 3224238 A1 20231005; EP 3738184 A1 20201118; EP 3738184 A4 20210929; EP 3738184 B1 20240214; EP 4042536 A1 20220817; EP 4042536 A4 20221221; EP 4042536 B1 20240320; EP 4042536 C0 20240320; EP 4348788 A1 20240410; JP 2021510291 A 20210415; JP 2022542491 A 20221003; JP 7213397 B2 20230126; JP 7325440 B2 20230814; MX 2020007286 A 20200925; MX 2022004089 A 20220719; US 10742025 B2 20200811; US 10938204 B1 20210302; US 11171483 B2 20211109; US 11451051 B2 20220920; US 11469592 B1 20221011; US 11689015 B2 20230627; US 2020044441 A1 20200206; US 2021305808 A1 20210930; US 2022224108 A1 20220714; US 2023147803 A1 20230511; US D1038036 S 20240806; WO 2019139933 A1 20190718; WO 2021071564 A1 20210415; WO 2022010535 A1 20220113; WO 2023080940 A1 20230511; WO 2023191846 A1 20231005

DOCDB simple family (application)
US 201916240897 A 20190107; AU 2019206390 A 20190109; AU 2020361439 A 20200709; AU 2022450393 A 20220909; BR 112020013897 A 20190109; BR 112022006478 A 20200709; CA 3088002 A 20190109; CA 3153874 A 20200709; CA 3224238 A 20220909; EP 19738984 A 20190109; EP 20874163 A 20200709; EP 22936010 A 20220909; JP 2020557140 A 20190109; JP 2022521670 A 20200709; MX 2020007286 A 20190109; MX 2022004089 A 20200709; US 2019012819 W 20190109; US 201916597427 A 20191009; US 2020041366 W 20200709; US 202016925600 A 20200710; US 2021012893 W 20210111; US 202117148168 A 20210113; US 202117521369 A 20211108; US 2022039676 W 20220808; US 2022043087 W 20220909; US 202217706041 A 20220328; US 202217888107 A 20220815; US 202229825905 F 20220207